



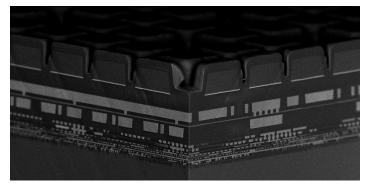
• 3D sample management for physical failure analysis

FIB/SEM tomography for 3D metrology

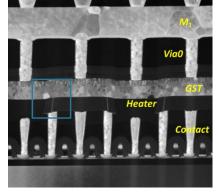
• E-tomography for nm scale 3D imaging



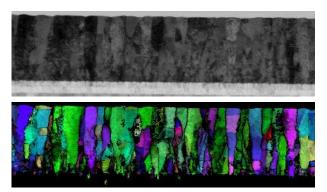
About ST Physical charac. Lab @ Crolles large portfolio for routine analysis



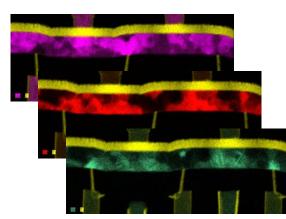
SEM imaging - 28FD stack

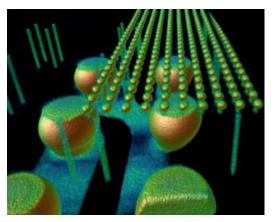


STEM imaging – PCM stack



Texture analysis in TEM



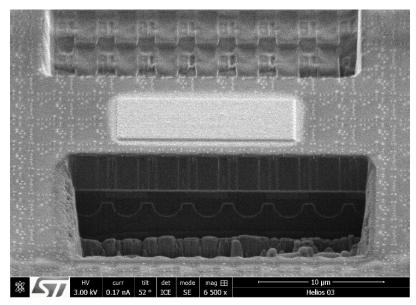


X-ray tomography Package (TSV & solder bumps)

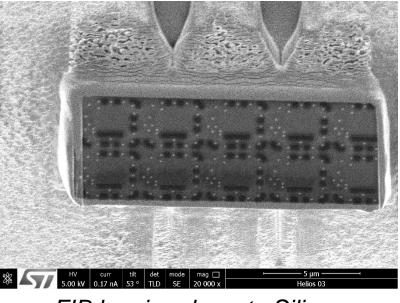


Chemical mapping STEM/EDX PCM

- Starting point : known failing device localization from FA (nanoprobing)
- Sample prep. : sample lifted excavated from wafer & top-down lapping with FIB



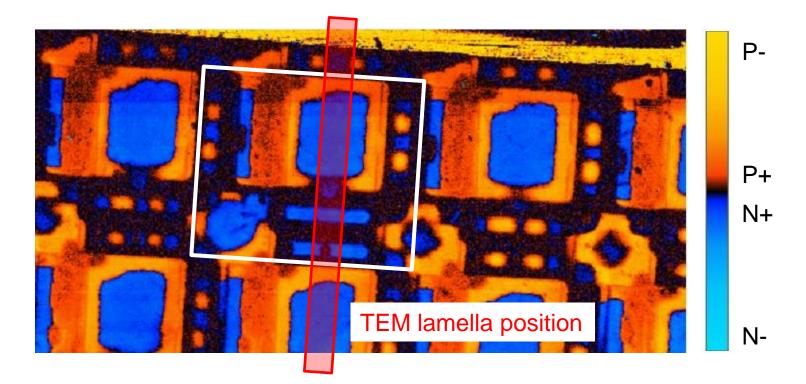
Region of interest extraction



FIB lapping down to Silicon



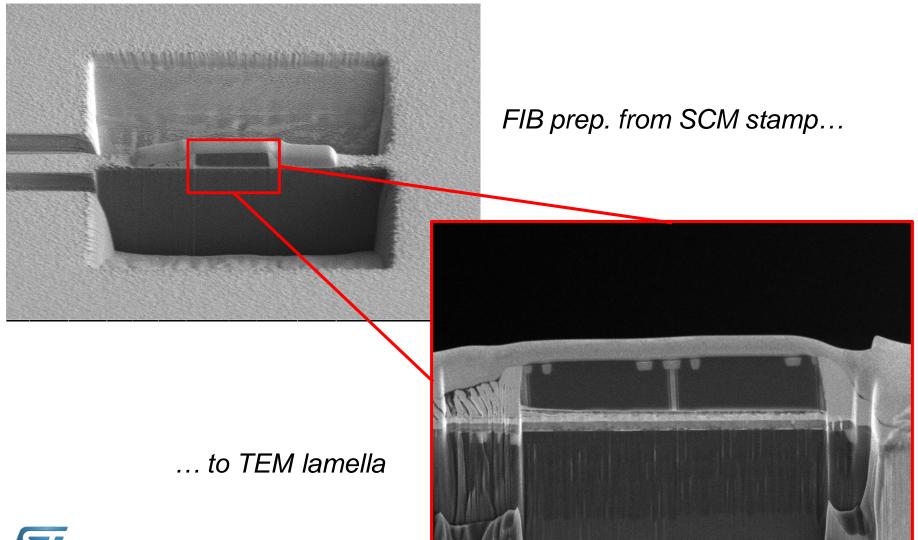
Dopant mapping performed using SCM (AFM based technique)



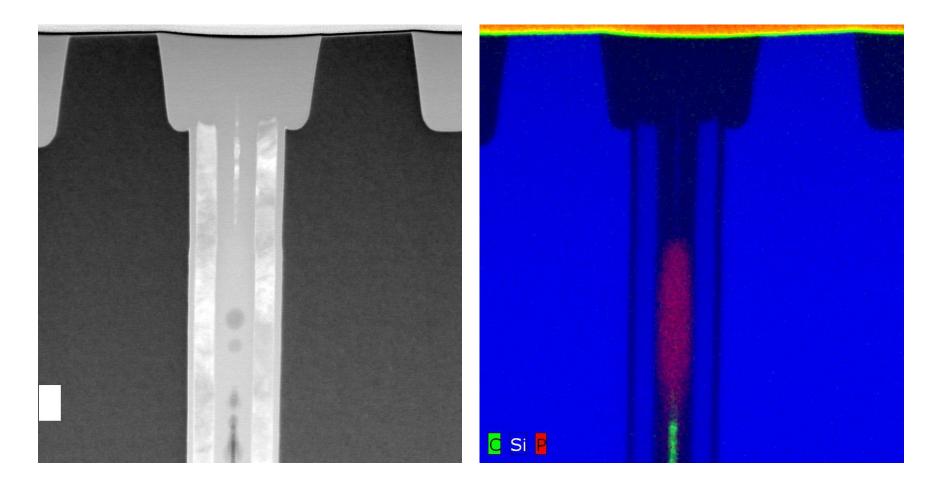
In plane analysis not sufficient for root cause understanding
 need transverse analysis



6



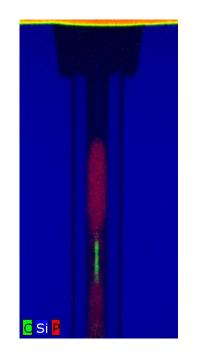


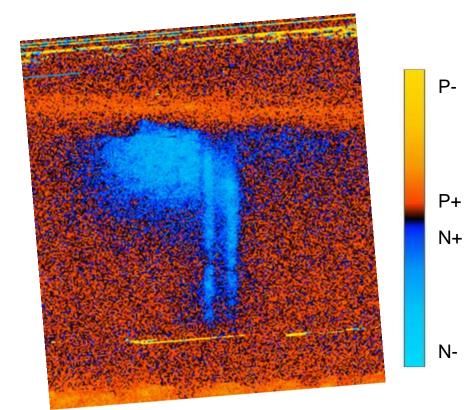


life, gugmented

STEM EDX mapping revealing abnormal P contaminant No electrical fail evidence yet

- Additional sample management
- From TEM lamella to SCM ready stamp





• Evidence of electrical fail issue

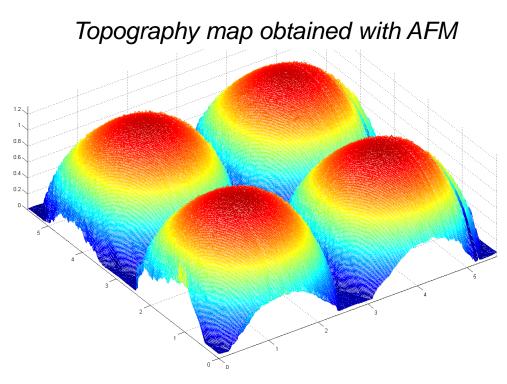
Need for a 3D approach/specimen mgt for root cause understanding

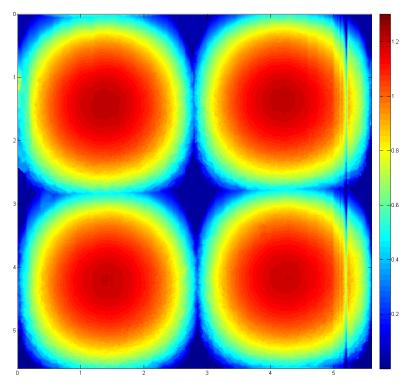


FIB/SEM 3D for 3D metrology case of microlenses

Microlenses

- in imaging/pixel architecture
- Shape of importance to determine photons path
- Conventional technique for topography: AFM





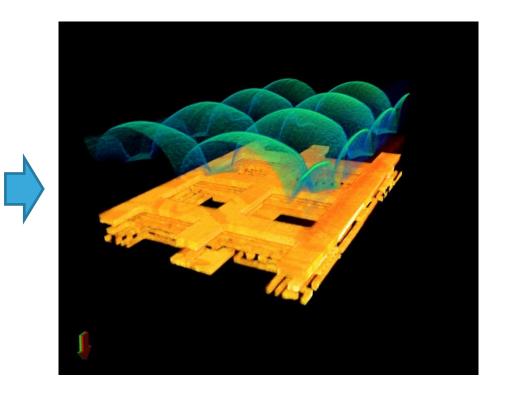


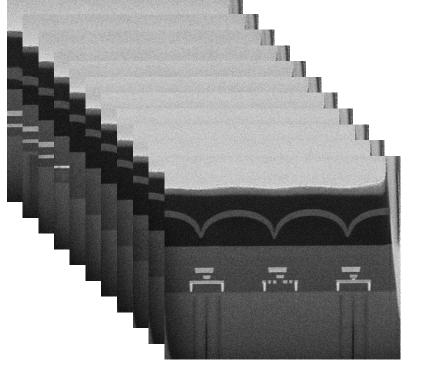
Questions about AFM results accuracy; needed for photons path simulation

FIB/SEM 3D for 3D metrology case of microlenses

µ-lens slicing and SEM imaging

Pixel architecture volume rendering



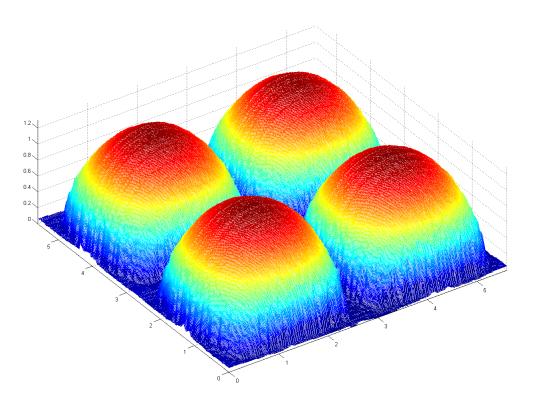


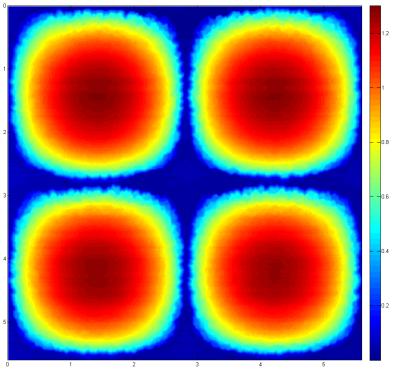
F/S3D acquisition : in routine analysis Deployment to team



FIB/SEM 3D for 3D metrology case of microlenses

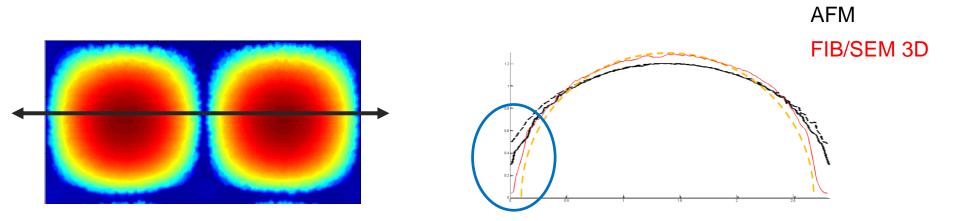
- Elevation mapping from FIB/SEM 3D
 - Obtained after segmentation
 - Script to provide AFM format results





FIB/SEM 3D for 3D metrology case of microlenses

AFM to FIB/SEM 3D comparison



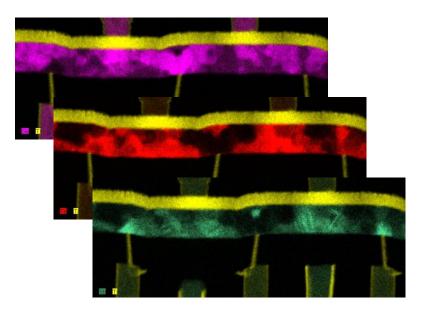
• Improvement of topography definition between lenses

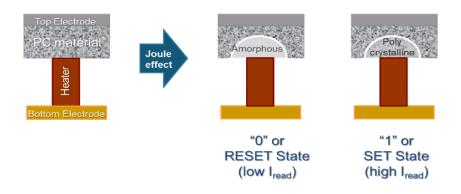
- Need for 3D metrology
- 3D approach required for charac. accuracy



E-tomography for nm scale 3D imaging case of GST compound density variation

- PCM architecture
 - Material with 2 distinct resistive states





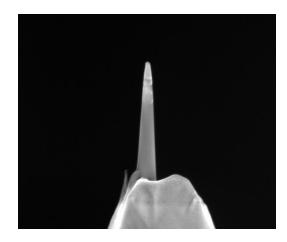
- Layer
 - $Ge_XSb_yTe_z$
 - Poly-crystal sample
 - Grains size & distribution
 influence on device behaviour properties



 Elemental mappings overlapping over TEM lamella thickness → need for local information

E-tomography for nm scale 3D imaging case of GST compound density variation

FIB prepared probe



STEM-EDX electron tomography

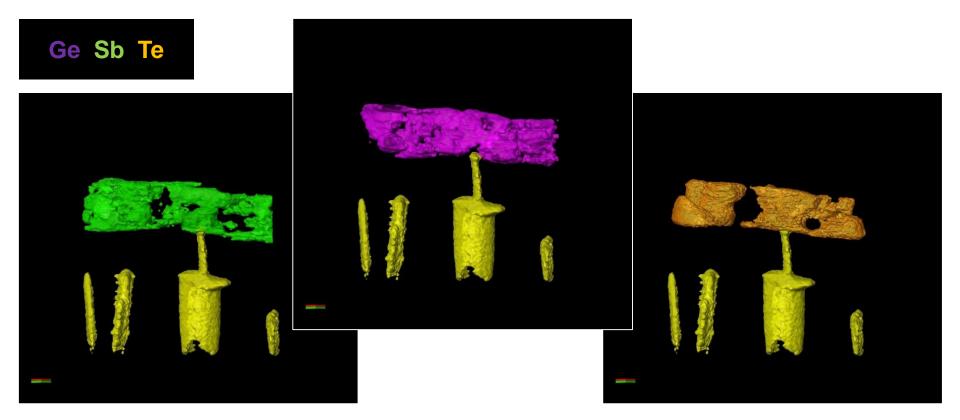
- Manual mappings acquisition
- Every 10° step, 180° range
- Long data treatment (engineering)



Volume rendering



E-tomography for nm scale 3D imaging case of GST compound density variation



- Individual species distribution within PCM layer can be analyzed
 - 3D need for complex material analysis



conclusions 16

- 3D approach and/or analyses required for IC development
 - Ready for industrial support or still engineering mode
- For all techno nodes
 - From packages to μm scale device, down to advanced scale (nm) nodes
- Still complex techniques
 - Sample prep.
 - Sample management /orientation for successul analysis
 - Can become (very) difficult when dealing with a specific device
 - SW / scripting needs
 - For data acquisition, data extraction, data management

